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Form 1449 (Modified)

Information Disclosure

Atty Docket No. KLA1P099

Application No.: 10/691,940

Applicant:

KLA-Tencor Filing Date

Group 288/

(Use Several Sheets if Necessary)

Statement By Applicant

October 22, 1003

Unassigned

U.S. Patent Documents

Examiner				T		Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
ICK	Α	5,877,498	03/02/99	Sugimoto et al.			07/15/97
1215	В	5,900,645	05/04/99	Yoshinki Yamada			11/21/97
1135	С	6,351,516	02/26/02	Mazor et al.			12/14/99
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	E						
	F						
	G					<u> </u>	
	Н		·				
	I						

Other Documents

Examiner						
Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication				
No	0	Amekura, Hiroshi et al., X-Ray Emission Induced by 60 keV High-Flux Copper Negative-Ion Implantation, February 2001, Japan Society of Applied Physics.				
No	P	Shaw, Judy B. et al., Voids, Pits, and Copper, Winter 2002, Yield Management Solutions: Cu/low Special Focus.				
W.	Q	Testoni, A.L., CuVA: Analyzing Voids in Cu Interconnects, June 20, 2002, KLA-Tencor Progress Report.				
Examiner	The	Sluta Bells Date Considered February 15, 2005				

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.